

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

December 24, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG759530832

LABORATORY GROWN DIAMOND

EMERALD CUT

6.65 X 4.90 X 3.34 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

1.06 CARAT

D

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence


EXCELLENT

EXCELLENT

NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

 LG759530832

PROPORTIONS

Medium

62%

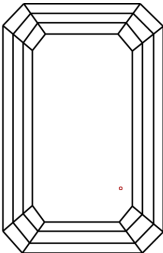
15%

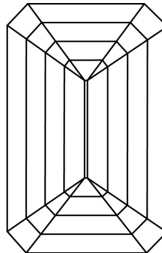
50%

68.2%

Long

CLARITY CHARACTERISTICS






KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

Sample Image Used



COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

FL

IF

VVS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Flawless

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence


EXCELLENT


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IGI

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IGI Report No LG759530832

EMERALD CUT

6.65 X 4.90 X 3.34 MM

Carat Weight

Color Grade

Clarity Grade

Depth

Table

Girdle

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

1.06 CARAT

D

VS 1

68.2%

62%


Medium

Long

EXCELLENT

EXCELLENT

NONE


 LG759530832

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

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